

**Notice of References Cited**Application No.  
**09/339,869**Applicant(s)  
**Koide et al**Examiner  
**A. Dexter Tugbang**Group Art Unit  
**3729**

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\* A copy of this reference is not being furnished with this Office action.  
(See Manual of Patent Examining Procedure, Section 707.05(a).)